Therm oelectric e ect in molecular junctions: A tool for revealing of transport mechanisms.

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W e investigate the therm opower of a m etal-m olecule-m etal junction taking into account therm al e ects on the junction. Based on analytical expressions and num erical simulations we show that the therm collectric potential reveals valuable inform ation on the m echanism s controlling the electron transfer process, including coherent transm ission and therm alized hopping. W e also show that at high tem peratures the position of the Ferm i energy relative to the m olecular states can be easily deduced from the therm collectric potential. Standard current-voltage m easurem ents are insensitive to this inform ation.

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I. IN TRODUCTION

Understanding of charge transfer processes through single molecules is at the forefront of molecular electronics [1]. The electrical conductance of a single molecule coupled to metal electrodes has been recently measured by dimerent techniques 2, 3]. In these experiments the current-voltage (I-V) characteristic of the device is measured, and information on the transport mechanism, the molecule-metal coupling strength, and the role played by nuclear motion in the conduction process are deduced.

Experimental data [4, 5, 6] and theoretical studies [7, 8, 9, 10, 11] suggest that two mechanisms are involved in electron transfer processes through molecular bridges: Super-exchange mechanism and thermal induced hopping. The super-exchange mechanism is a coherent (tunneling) and short distance charge-transfer process. It dom inates transport when the molecular levels relevant for transport-Ferm i level o set is greater than the therm al energy. In the opposite lim it electron transm ission occurs through sequential hopping along the bridge. This is a multistep process that allows long distance charge transfer. In a typical I-V experiment transport mechanism s are analyzed based on Arrhenius plot, revealing a characteristic transition from tem perature (T) independent behavior at low T to a strong dependence at high T [6].

It was recently suggested that them oelectric measurements could provide additional insight into electron transport through single molecules, and contain inform ation on the electronic and vibrational excitation spectrum of the molecule [12, 13, 14].

In a them oelectric experiment the electric current induced by a nite temperature di erence is investigated. A lternatively, the potential under the condition of zero current is measured. The therm oelectric power of microstructures such as quantum dots [15], single electron transistors, [16] and mesoscopic nanotubes [17, 18] has been of interest since it yields directly the sign of the dominant charge carriers and the intrinsic conduction properties. In addition, it is sensitive to the electronic structure at the Ferm i level. In two recent studies the them oelectric voltage over a conjugated molecular conductor [12] and an atom ic chain [13] was calculated. It yields valuable information- the location of the Ferm i energy relative to the molecular levels. Inelastic interactions on the bridge were neglected in both cases. In a di erent work K och et al. [4] investigated the thermopower of a single molecule when both sequential tunneling (low est order tunneling process) and cotunneling (second order tunneling processes) take place. V ibrational features of the molecule were taken into account, but direct therm alactivation of electrons onto the bridge and the possibility of di usional transport were not included. In addition, this study was limited to the shortest molecular unit made of a single electronic state.

In this paper we extend these ideas and analyze the therm oelectric voltage of a molecular junction of bridge length N > 1 while taking into account both coherent and therm al interactions in a uni ed theory. Our model includes relaxation mechanisms on the bridge, arising from the interaction of the electronic system with other bridge or environm ental degrees of freedom . The e ect of these interactions is to open up a therm al channel for conduction. Hence in our model electrons can be transm itted through the bridge either coherently (tunneling), or by sequential hopping. We focus here on the nonresonant regime, where bridge energies are far above the chem icalpotentials of the metals. In this lim it the actual population of electrons on the bridge is very small, and e ects due to charging of the bridge (coulom b blockade) are negligible.

We show through simple approximate expressions and with numerical examples that the functional behavior of the therm oelectric voltage is intrinsically diment for the diment modes of transfer, and that it clearly remets the turnover between the two mechanisms. The therm oelectric phenomena can therefore serve as a signing cant tool for analyzing transport mechanisms complementing traditional techniques. In addition, we menting traditional techniques. In addition, we menting tramal interactions dom inate the transport, the molecular levels Ferminenergy gap for transmission can be easily deduced from the therm opower value. This last property is crucial for interpreting I-V results in transport experim ents.

The model system consists of a metal-molecule-metal junction under an electrical bias and a therm algradient. The molecule is described by a tight binding model with N sites with one state localized at each site. The rst and last states are coupled to the left (L) and right (R) metal leads respectively. At equilibrium, $_{\rm F}$ speci es the Ferm i energy of the two metals, taken as the zero of energy. Under a potential bias the leads are characterized by electrochemical potentials $_{\rm L}$ and $_{\rm R}$ for the L and R sides. In addition, the two metals are kept at di erent tem peratures $T_{\rm L}$ and $T_{\rm R}$. For a schematic representation see Fig. 1.

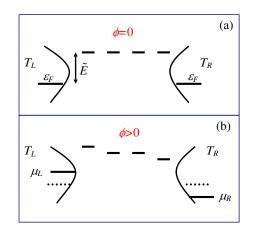


FIG. 1: (Color online) Scheme of the model system : A molecule of N sites connecting two metal leads. (a) No applied bias. (b) e > 0.

We investigate the therm oelectric e ect in this system using a variation of them odel developed before to analyze therm alle ects in electron transm ission through molecular bridges [9, 25]. There, the molecular system and the metals were in contact with a single therm all reservoir held at temperature T. Here, in contrast, we specify only the temperatures of the charge reservoirs (metals), and from this boundary condition the molecular temperature should be deduced. We explain below how to implement this modication into the formalism of Ref. 9].

The system Hamiltonian includes ve terms

$$H = H_{M} + H_{K} + H_{MK} + H_{B} + H_{MB} : (1)$$

Here H $_{\rm M}\,$ denotes the isolated m olecule of length N with one electronic state at each site

$$H_{M} = \begin{array}{ccc} X^{N} & X^{N} \\ E_{j} j j j i h j j + V \\ j = 1 \end{array}$$
(jj i h j 1 j + j 1 i h j j): (2)

The bridge energies E_j are taken to be equal at all sites at zero bias, $E_j = E' \cdot V$ is the nearest neighbors electronic

coupling. The left and right charge carriers reservoirs (m etals) are described by their set of electronic states

$$H_{K} = \begin{array}{c} X & X \\ r jrihrj + \\ r^{2 R} \\ \end{array} \begin{array}{c} X \\ 1 \\ jlihlj; \\ (3) \end{array}$$

The leads are held at constant tem peratures $T_{\rm L}$ (left) and $T_{\rm R}$ (right). In what follows we use the notations $T_{\rm a}$ = $(T_{\rm L}$ + $T_{\rm R}$)=2 and T = $T_{\rm L}$ $T_{\rm R}$. The molecule-metals interaction term is

$$H_{M K} = V_{1;1} jlihlj + V_{r;N} jrihN j + cr:; (4)$$

yielding the relaxation rate $_{\rm L}$ () = 2 $\begin{bmatrix} 1 \\ 12 \\ {\rm L} \end{bmatrix} y_{1,1} \frac{2}{1}$ (1), and an analogous expression for $_{\rm R}$ at the R side.

Them olecule is in contact with therm aldegrees of freedom, both internal (vibrations), and those related to the motion relative to the leads, all denoted as a "therm al bath" and included in H_B . The last term in the Ham iltonian (1) describes the coupling of this therm albath to the molecule. Speci cally we use the following model for this interaction

$$H_{M B} = F_{jjjihjj}$$
(5)

where F_j are bath operators and jji are molecular states, j = 1::N. The form of Eq. (5) in plies that the therm all bath induces energy dephasings on the local bridge sites. The bath operators are characterized by their time correlation function

$$\begin{array}{c} Z_{1} \\ e^{i! t} h_{F_{j}}(t) F_{j^{0}}(0) i = e^{i! t} h_{F_{j^{0}}}(0) F_{j}(t) i; \quad (6) \\ 1 \end{array}$$

where $= 1 = k_B T$, T is the local therm albath tem perature and k_B is the Boltzm ann constant. A ssum ing that therm al interactions on di erent molecular sites are not correlated, and going into the markovian limit, the correlation function becomes

$$hF_{j}(t)F_{j^{0}}(t^{0})i = j_{j^{0}}(t^{0})i$$
 (7)

Here is the dephasing rate re ecting the strength of the system -bath interaction: W hen = 0, the electronic system and the therm al degrees of freedom are decoupled, and electrons m ove coherently along the wire. In contrast, strong dephasing rates in ply the dom inance of the incoherent transm ission m ode [9]. It should be emphasized that the bridge dephasing rate and the electronic couplings between the sites V are in general temperature dependent. Since in the nonresonant regime therm al activation is the dom inant temperature dependent factor, we sim plify the discussion and ignore these corrections. The therm al bath temperature therefore enters the form alism only through the detailed balance condition, Eq. (6).

The transport behavior of the system depends, among other factors, on the way the potential bias falls along the m olecular bridge. In what follows we use the following model for the electrostatic potential pro le

$$L = F + e = 2; R = F e = 2;$$

$$E_{1} = E' + e = 4; E_{N} = E' e = 4;$$

$$E_{j} = E'; j = 2:N 1: (8)$$

The qualitative aspects of the results presented below are not a ected by this particular choice, since the relation $E = E_{F}$ > e is retained in this work.

In the weak molecule-therm al bath coupling limit a computational scheme for evaluating the energy dependent transmission coe cient through a metal-molecule-metal junction for the $T_L = T_R$ case was developed in Ref. [9]. The method is based on the generalized quantum master equations extended to steady state situations. Here we further extend this framework and study therm oelectric e ects in molecular junctions.

III. THERMOPOWER

The current through the junction is calculated by generalizing the Landauer form ula [19] to situations involving inelastic interactions on the bridge [20, 21]

$$I = I_{L!R} \xrightarrow{P} I_{Z'L};$$

$$I_{L!R} = \frac{e}{2} d_{0} d_{f}T_{L!R} (_{0}; _{f})f_{L} (_{0}) (1 f_{R} (_{f}));$$

$$I_{R!L} = \frac{e}{2} d_{0} d_{f}T_{R!L} (_{0}; _{f})f_{R} (_{0}) (1 f_{L} (_{f})):$$
(9)

Here $T_{L\,!\,R}$ (_0; _f) denotes the transm ission probability for an electron incoming from the left lead at the energy _0 to be emitted at the opposite side at _f. The energy di erence _f __0 is exchanged with the therm al environment. This coe cient depends on the molecular parameters, the applied potential, the metal-molecule interaction, temperature and dephasing. It is not necessarily the same for the di erent directions. The current (de ned positive when owing left to right) is evaluated by weighting the transm ission probability by the appropriate combination of the Ferm i distribution functions at the metals f_K () = e^{\kappa} ($_{K}$) + 1 1 where $_{K}$ ($_{R}$ T_{K}) 1 is the inverse temperature (K_{R} $_{L}$ $_{R}$). Unless speci ed, the integrals are all taken as $_{1}$.

The generalized Landauer equation does not take into account the e ect of the contact population on the inelastic processes. Including such e ects can be implemented by replacing the Ferm i occupation factors by nonequilibrium electron distribution functions [7]. Yet it can be shown that Eq. (9) well approximates the current when the transmission through the junction is signi – cantly small (< 1) [22]. Since we focus here on the out of resonance, sm all bias, weak electron-phonon interaction and weak m etal-m olecule coupling situation, transm ission probabilities are always sm all and Eq. (9) can be utilized. The inelastic Landauer form ula can be also derived using the system atic nonequilibrium G reen function approach. Recent calculations of inelastic tunneling currents yield an expression sim ilar to (9) assum ing weak coupling to the leads, weak electron-phonon coupling, and sm all bias [23]. For recent discussions on the issue see Refs. [14, 22, 24].

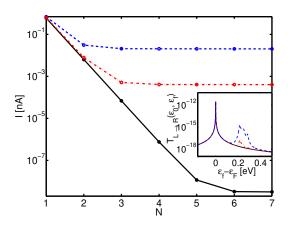


FIG.2: (Color online) Electron current vs. wire length N for di erent tem peratures: T = 300 K (dashed), T = 200 K (dashed-dotted) and T = 100 K (full). The other parameters are E = 250 m eV, V = 25 m eV, e = 2.5 m eV, $_{\rm L}$ = $_{\rm R}$ = 15 m eV, = 1 m eV. The inset presents the respective L to R transmission probability T_{L! R} for N = 3 and $_{\rm 0}$ = $_{\rm F}$.T = 300 K ,200 K,100 K top to bottom.

We calculate next the current owing through a biased N level molecular junction. We inst consider the simple situation of $T_L = T_R = T$, i.e. we do not apply an external temperature gradient. Since this system was analyzed extensively in previous works, Refs. [9, 25], we present here only the main results. Fig. 2 demonstrates the distance dependence of the current at dimensional temperatures. The following set of parameters is used: E = 250 meV, V = 25 meV, e = 2.5 meV and e = 1 meV (Typical dephasing times in condensed phases are of order of 1 ps). The inset depicts the corresponding energy resolved transmission probability for an electron incoming at $_0 = _F$ for the N = 3 case.

The following observations can be made: (i) The transmitted ux consists in general two main components: elastic tunneling at $_{\rm f} = _0$ and activated ux in the energy range of the bridge states E. These two components can be clearly distinguished when bridge energies are high enough, E $k_{\rm B}$ T and the coherent interaction V is much smaller than E. (ii) The coherent component is most important at low temperatures, large energy gaps and short chains. The incoherent contribution dom inates in the opposite limits. (iii) The electric current manifests a clear transition from an exponential decay typical to tunneling for short chains, to a weak (algebraic) distance dependence for longer chains, characterizing them alactivation into the bridge. The turnover is shifted into higher N values when the tem perature is low ered. (iv) The therm alcom ponent of the transm ission is exponentially enhanced when increasing the tem perature. In contrast, the e ect of the dephasing is more subtle. W hen the dephasing rate is very sm all < 0.01 m eV(using the param eters of Fig. 2), transport is coherent and the current increases with . For very high dephasing values, 100 m eV, coherent e ects are com pletely destroyed and the current goes down like 1= . See R ef. [9] for details. In this work we employ the interm ediate values of 0:1 10 m eV .

Following these observations we can approximate the transmission coecient by a generic functional form containing only its main features: For large energy gaps and for reasonable temperaturesmixed coherent-inelastic contributions can be safely neglected and the transmission is approximated by two separate terms [9, 25]

$$T = T_{tunn} + T_{hopp} :$$
 (10)

The rst term stands for tunneling

$$T_{tunn} (_{0}; _{f}) = (_{0} _{f})A (_{0}); \qquad (11)$$

while the second contribution reproduces therm alized hopping through the junction

$$\Gamma_{hopp}(_{0;f}) = B(_{0;f}) e^{(E_{B} 0)} : (12)$$

 E_B is an elective bridge energy. It is related closely to the gap E of the molecule in an equilibrium situation, but it is modiled by the molecule-metal interactions and the applied potential. The coelections A and B depend on the molecule-metal coupling terms, the energetics of the bridge, its length, and on the thermal parameters T and . Here we assume that A does not depend on the thermal parameters, and that B is the same when exchanging between the initial and nalenergies, B ($_0$; $_f$) = B ($_f$; $_0$) [9]. In what follows we utilize Eqs. (11)-(12) for deriving simple expressions for the therm opower coelection.

W e proceed to the relevant case of an electrically biased junction under an additional temperature gradient. In our model the temperatures of the two leads L and R are kept xed at \underline{T}_L and T_R respectively, while the temperature of the molecular degrees of freedom is adjusted to the boundary conditions: At a steady state situation the temperature distribution along the molecule is determined, among other factors, by the metals temperatures, the rate of energy dissipation on the molecule, and the rate at which energy is transferred away from the conductor [25, 26]. Here we do not calculate this temperature gradient, but assume that at the left end of the molecular chain the temperature is nearly T_L , and similarly at the right edge it is close to T_R .

W e assume next that the transm ission $T_{K ! K \circ}$ depends on the tem perature $T_K (K = L, R)$, but is independent of

 $T_K \circ$. Under this approximation the transmission coe – cient in Eq. (9) can be calculated using the procedure of Refs. [9, 25] without modi cations, simply by employing the di erent tem peratures when evaluating $\mathbb{T}_{! R}$ and $T_{R\,!\ L}$. This approximation relies on the fact that in the K ! K⁰ transm ission process the temperature at the K end dom inates the transport. This is true considering both transport mechanisms, tunneling and sequential hopping: Hopping through the bridge is triggered by therm alactivation from the metal, see Eq. (12). A ssum ing that this is the rate determ ining step, the relevant tem perature is therefore ${\tt T}_{\tt K}$. The tunneling contribution to transm ission depends very weakly on the bridge's tem perature [9]. This naive approximation is adjusted by maintaining T ! O. Note that a full self consistent formalism (For example the Keldish-Kadano formalism [27]) should naturally yield the tem perature distribution on the junction without such assumptions.

We de ne the therm oelectric voltage $j_{E=0}$ as the voltage necessary for neutralizing the temperature induced current. The therm opower is the ratio of the potential energy e to the temperature di erence T under the condition that the current vanishes

$$S = \lim_{T ! 0} \frac{e}{k_B T} = 0$$
 (13)

We discuss next the limiting behavior of the therm opower ratio for the di erent transport mechanisms. The net current is calculated by considering separately the elastic (tunneling) and inelastic (hopping) components, Eqs. (10)-(12). The tunneling current reduces to the standard Landauer form ula [19]

$$I_{tunn} = \frac{e}{c} d_{0}A(0) [f_{L}(0) f_{R}(0)]:$$
(14)

A ssum ing the transm ission is a smooth function of the energy in comparison to $k_B \; T_a$, it can be expanded around $_F$

$$A() = A(_{F}) + \frac{@A}{@} (_{F}) + \frac{1}{2!} \frac{@^{2}A}{@^{2}} (_{F})^{2} + \frac{1}{3!} \frac{@^{3}A}{@^{3}} (_{F})^{3} + \dots$$
(15)

In the linear response regime of small T and the Ferm i functions in Eq. (14) are further expanded linearly

$$f_{L}() \quad f_{E}() = \frac{\theta f(;_{F};T_{a})}{\theta} e + \frac{T}{T_{a}}(F) :$$
(16)

Here the derivative of the Ferm i function is calculated at the average values T_a and $\ _F$. W hen we consider only the

rst two term s in Eq. (15) in conjunction with Eq. (16), we obtain the standard lowest order expression for electron current due to both electric bias and temperature gradient [12, 13, 28]

$$I_{tunn} = \frac{e^2}{2} A(F) + \frac{e}{2} \frac{2k_B^2 T_a}{3} \frac{QA}{Q} = T: (17)$$

The current through the device is zero when the potential di erence is set to

$$\dot{J}_{=0} = \frac{\frac{2 k_{\rm B}^2 T_{\rm a}}{3 e} \frac{\varrho \left(\ln \left(A\right)\right)}{\varrho}}{\frac{1}{2} E_{\rm F}} T:$$
(18)

W hen higher order terms in A are necessary, we utilize the Sommerfeld expansion [29] and get a power law series in T_a for the therm coelectric potential

$$\dot{J}=0$$
 $\frac{k_{\rm B}}{e^{\rm A}} \left({}_{\rm F} \right) = {}_{n=1;3;5:...} \frac{{}_{\rm Q}{}^{n}{}_{\rm A}}{{}_{\rm Q}{}^{n}} {}_{\rm F} \left(k_{\rm B} T_{\rm a} \right)^{n} :$ (19)

W e can further consider an explicit expression for A. If the bridge energies lies well above $_L$ and $_R$, a perturbative treatment leads to the superexchange result [30]

A (_0)
$$\frac{V^{2N}}{(E_B _0)^{2N}}$$
 : (20)

Here V is the coupling matrix element in the bridge and = K is the relaxation rate to the K metal. We substitute this relation into Eq. (19) and get the tunneling contribution to the therm opower

$$\frac{e \ \mathbf{j}_{=0}}{k_{\rm B} \ T} \quad \sum_{n=1,3,5:...}^{X} (2N)^{n} \frac{(k_{\rm B} \ T_{\rm a})^{n}}{(E_{\rm B} \ F)^{n}} \quad S_{\rm T}: \quad (21)$$

This expression, though approximate, provides us with the important features of S_T : the inverse dependence with energy gap, and its enhancement with size and tem – perature.

W hen the gap ($E_B = F$) is large and the bridge size N is long such that A is practically zero away from the bridge energies, i.e. A() / (E), the tunneling contribution from F approaches zero. Electron transmission occurs then mainly via electrons in the tails of the Ferm i distributions in the leads at energies around E_B . In this ballistic regime the current, Eq. (14), is zero when f_L (E_B) = f_R (E_B) or

$$_{L}(E_{B}) = _{R}(E_{B}) : (22)$$

Using $T_L = T_a + T=2$, $T_R = T_a = T=2$, L = F + e = 2and R = F = e = 2, it reduces to

$$\frac{e \, \mathbf{j}_{=0}}{k_{\rm B} \, \mathrm{T}} = \frac{E_{\rm B} \, \mathrm{F}}{k_{\rm B} \, \mathrm{T}_{\rm a}} \qquad S_{\rm B}: \qquad (23)$$

This is the therm opower ratio in the ballistic regime: Electrons physically populate the molecule, but inelastic elects on the bridge are neglected. The therm opower in this case scales like T_a^{-1} , in accordance with previous studies [14].

Next we estimate the therm opower when therm al interactions govern the transport across the bridge. We substitute Eq. (12) into Eq. (9) using $= \frac{1}{K}$ for the $T_{K\ !\ K}\circ$ calculation, and get the net therm al (hopping) current

$$I_{hopp} = \frac{e}{\tilde{c}} d_{f} d_{0}B(_{0};_{f})(1 f_{L}(_{0}))(1 f_{R}(_{f}))$$

$$h^{\tilde{c}} i = \frac{i}{\tilde{c}} e^{-i} e^{-i} i = (24)$$

It is zero when the term in the square parentheses vanishes, i.e.

$$_{L}(E_{B} _{L}) = _{R}(E_{B} _{R});$$
 (25)

which leads to

$$\frac{e \ \mathbf{j}_{=0}}{k_{\rm B} \ \mathrm{T}} = \frac{E_{\rm B} \ \mathrm{F}}{k_{\rm B} \ \mathrm{T}_{\rm a}} \qquad S_{\rm H} : \qquad (26)$$

This result is equivalent to Eq. (23). There we considered resonant-coherent-transmission through a long chain, when tunneling from the Ferm i energy is negligible. Therefore, we cannot distinguish in the therm opower between transport due to therm all activation from the lead to the molecule and band motion of electrons at the tails of the Ferm i function. We refer to both as therm all mechanism s.

W e com pare next the tunneling therm opower term $\,S_{\,T}$, Eq. (21), to the therm alized behavior $S_{\rm H}$, (Eqs. (23), (26)). The following observations can be made: (i) S_{T} $(T_a = E)^n$, while S_H $E = T_a$. Here E E_B (ii) The tunneling term depends on the length of the molecule N. (iii) In both cases S does not depend on the m olecule-m etal interaction strength, given by the param eter . (iv) M easurement of S vs. T_a should yield the e ective energy gap for transmission, and also hint on the transport mechanism. We expect that when increasing the tem perature, the therm opower should rst increase (tunneling behavior governs at low tem peratures), then decay in a T_a^{-1} fashion when therm all activation dom inates electron transfer.

IV . RESULTS

W e investigate the therm opower behavior in ourm odel system, Eqs. (1)-(8), and show how the approxim at expressions, Eqs. (21) and (26), agree well with the num erical results. W e also extract in portant energetic and dynam ic inform ation from the therm oelectric potential. The following set of parameters is used: N 1-5 units, molecular energies E 100-500 m eV ($_{\rm F}$ is taken as zero). We focus on the $\lim it E' > V$ using V = 25 m eV. The metal-molecule relaxation rate is taken equal at the L and R sides, $_{\rm K}$ = 15 m eV. The system bath interaction is given by the dephasing parameter, 0:5 10 meV.

Fig. 3 shows the I-V characteristic for a chain of size N = 4 for di erent energy gaps E using $T_L = 335$ K and $T_R = 300$ K.W ithin this set of parameters the current is dominated by thermal elects, see Fig.2. Note that the

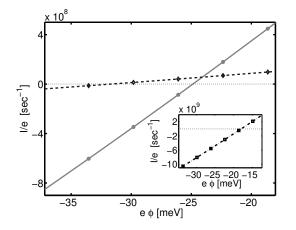


FIG.3: I-V characteristics of the N = 4 junction. The system parameters are = 5 m eV, $T_L = 335$ K, $T_R = 300$ K.E = 315 m eV (dashed), E = 250 m eV (full). The dotted line shows for reference the I=0 function. Inset: E = 185 m eV.

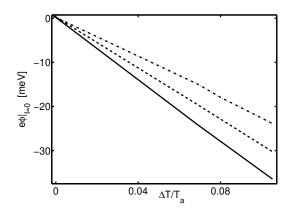


FIG.4: The therm celectric voltage plotted against $T=T_a$ for di erent m etal-m clecule energy gaps. E = 375 m eV (full), E = 315 m eV (dashed), and E = 250 m eV (dashed-dotted). N = 4, = 5 m eV, T = 30 K.

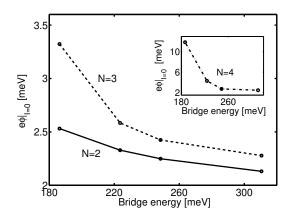


FIG.5: Dependence of the therm celectric voltage on the bridge energy (E) in the superexchange regime. = 0.5 meV, $T_a = 100 \text{ K}$, $T = -20 \text{ K} \cdot \text{N} = 2$ (full), N = 3 (dashed). Inset: N = 4.

I-V characteristic is expected to be linear for $k_B T_K$ for both coherent and incoherent modes of transfer [25]. This property enables easy and accurate evaluation of the $j_{\pm 0}$ value by a linear tting of a few I-V data points.

We nd that the results perfectly agree with Eq. 26). For E = 315 meV (dashed) the current vanishes at e $j_{1=0} = -32 \text{ meV} \cdot W$ hen utilizing Eq. (26) this number provides an e ective energy gap of $E_B = 290 \text{ meV}$. This value is in agreem ent with the low est diagonalized bridge V = 315-25= 290 m eV. The same beenergy of E havior is obtained for E = 250 meV (full) where we get e $j_{1=0} = -25 \text{ meV}$, leading to $E_B = 227 \text{ meV}$. For E = 187m eV (inset) the zero-current voltage is e $\dot{I}_{=0} = -18$ m eV and the resulting gap is $E_{\rm B}$ = 163 m eV .W e note that the e ective energy gap $E_{\!B}\,$ calculated (or m easured) based on the therm oelectric e ect is the real gap in the system, taking into account naturally and consistently the m etalm olecule interaction, the therm ale ects and the applied bias.

Fig.4 dem onstrates the tem perature dependence of the therm oelectric voltage within the same range of param – eters. It provides another evidence that in the present case transport is dom inated by therm all activation as $_{I=0}$ / $T=T_a$, in agreement with Eq. (26). The slopes for the E' = 375;315;250 meV cases are 316, 267, 217 meV respectively, producing the electric gaps. Note that for dillement therm oelectric voltages the bridge energies are slightly varied according to Eq. (8). For accurate results measurements should be done at T ! 0.

W e turn now to the low tem perature regim ewhere tunneling is expected to dom inate charge transfer. Fig. 5 presents the potential $j_{=0}$ for various chain lengths as a function of the energy gap E using $T_a = 100 \text{ K}$ and = 0.5 m eV. Indeed we indicate the therm coelectric voltage decreases with increasing gap in contrast to its behavior (in absolute values) in gures3 and 4. In addition, the therm coelectric voltage is larger for longer bridges. These observations are consistent with Eq. (21).

Next we show that the tem perature induced turnover between coherent motion to incoherent transmission is re ected in the therm oelectric potential. Fig.6 exem plies this behavior. We observe mainly three regimes in the main curve: (a) The potential is almost zero. (b) e $j_{=0}$ increases strongly with T_a . (c) Above the threshold of T_a 150 K the potential saturates, then goes $T=T_a$. We can explain these results as down like / follows: (a) At very low tem peratures the therm oelectric potential is close to zero as tunneling transm ission through the bridge is very small. Ballistic motion is not signi cant because of the low population of electrons at the m etals around E $_{\rm B}$. (b) W hen the tem perature is increased electrons populate energies in the metals above the Ferm i energy and tunneling becomes more probable. B and m otion and therm alized hopping also begin to contribute. (c) In this regime transport occurs through physical population of the bridge, and the therm opower behaves in accordance with Eq. (26). To conclude-while in region (a) transport is dom inated by coherent interactions, in region (c) it is induced by therm all ects. The interm ediate area (b) presents a regime where coherent e ects and therm al interactions m ix. The inset displays the A rhenius plot of Ln current vs. inverse tem perature for a representative applied potential, e = 6 m eV (The results do not depend on the applied voltage for e up to

 $30\ meV$). The dimension error regimes are marked according to the main plot. A clear transition at T_a $100\ K$ is observed: The current becomes temperature independent for lower temperatures since tunneling dominates. The behavior at region (c) is also clear: Ln (I) / $1=T_a$. In contrast, the behavior at the central area is obscure, and no clear transition is observed at T_a $150\ K$. Thus, therm opower measurements may complement standard I-V studies, yielding valuable information about the junction energetics and charge transferm echanism s.

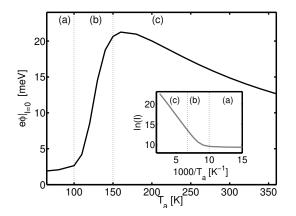


FIG.6: Tem perature dependence of the therm celectric voltage. E = 250 meV, N = 4, = 1 meV, T = -20 K. Inset: A rihenius plot of current vs. inverse tem perature for e = 6 meV.

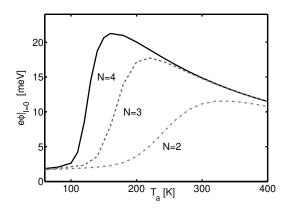


FIG.7: Tem perature dependence of the therm celectric voltage for di erent bridge lengths. N = 4 (full), N = 3 (dashed), N = 2 (dashed-dotted). E = 250 m eV, = 1 m eV, T = -20 K.

Finally, Fig.7 displays the them oelectric potential vs. tem perature for m olecules of di erent sizes: N = 4 (full), N = 3 (dashed), and N = 2 (dashed-dotted). We nd that for short chains the transition points between the three regim es are shifted to higher tem peratures as coherent effects persist. For the N = 2 chain transport is still largely controlled by tunneling at room tem perature. A nother im portant feature of the therm oelectric potential is its independence on N at high tem peratures, while it is strongly size dependent at low T_a . This observation is consistent with expressions (21) and (26).

V. SUMMARY

U sing a simple model for electron transfer through a molecular junction, taking into account both coherent effects and them al interactions in the molecule, we have calculated the therm opower of the device assuming weak molecule-leads and weak molecule-therm albaths interactions. We have shown that the therm opower can provide information on charge transfer mechanisms, and that it can reveal the location of the Ferm i energy relative to the molecular levels. Therm opower measurements can thus complement standard I-V experiments, with the advantage of their insensitivity to the metal-molecule contact. For example, the therm opower can be used for comparing of transport experiments done on the same molecules but with di erent contact interactions and measurement methods [31].

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